

Electrochemical Deposition of Copper on Epitaxial Graphene

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Supplementary Materials

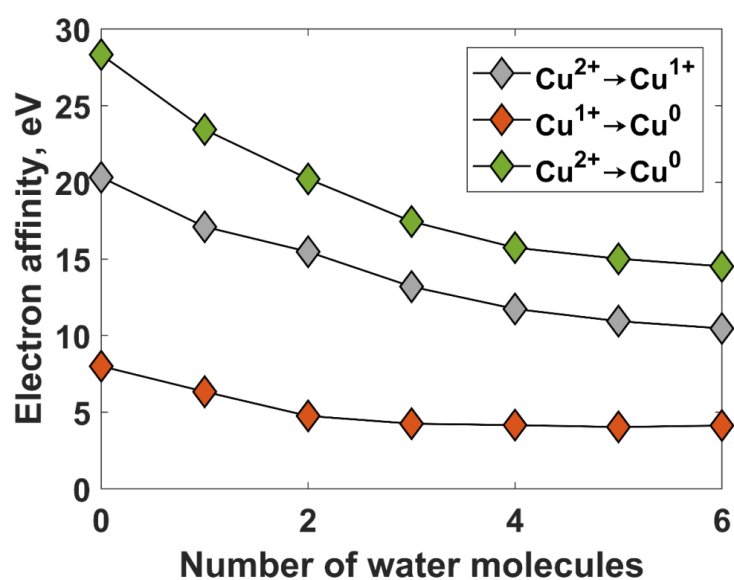


Figure S1. The decrease of the computed electron acceptor reactivity with the addition of the water molecules into the aquo complexes.

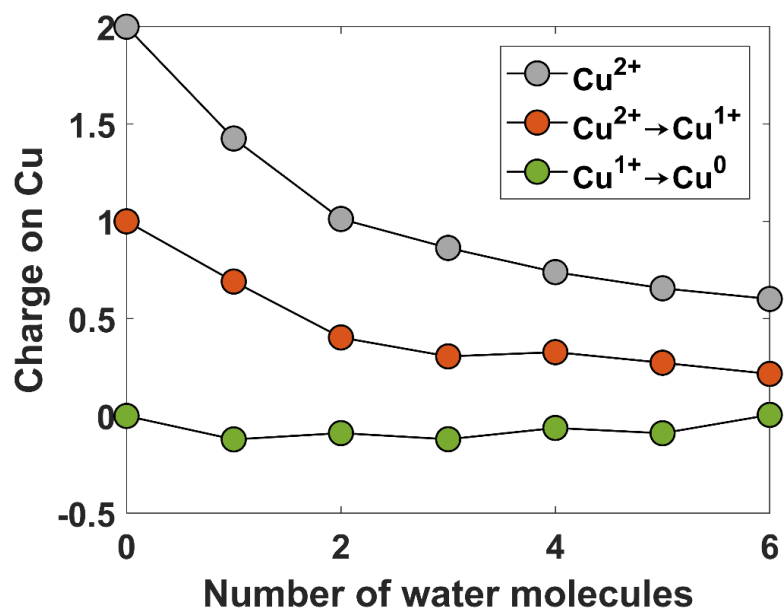


Figure S2. The change in Hirshfeld charge on Cu species with the addition of the water molecules into the aquo complexes.